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| Substitute Form PTO-1449 (Modified) | | U.S. Department of Commerce Patent and Trademark Office | | Attorney's Docket No. 07977-280001 | Application No. 09/894,950 |
| Information Disclosure Statement by Applicant (Use several sheets if necessary) (37 CFR §1.98(b)) | | Applicant Shunpei Yamazaki et al | | | |
| | | | | Filing Date June 27, 2001 | Group Art Unit 2825 |

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| Examiner Initial | Desig. ID | Document Number | Publication Date | Country or Patent Office | Class | Subclass | Translation |
| | | | | | | | Yes No |
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| Examiner Signature <i>C. Juerkstall</i> | Date Considered 10-6-05 |
| EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. | |

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| Substitute Form PTO-1449 (M-1449) | | U.S. Department of Commerce Patent and Trademark Office | Attorney's Docket No. 07977-280001 | Application No. 09/894,950 |
| Information Disclosure Statement by Applicant <small>(Use several sheets if necessary)</small> | | Applicant Shunpei Yamazaki et al | | |
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| EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. | |